

Notice of References Cited	Application/Control No. 10/690,315	Applicant(s)/Patent Under Reexamination YOO, WOO SIK	
	Examiner Asok K. Sarkar	Art Unit 2829	Page 1 of 1

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*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
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	B	US-6,043,004	03-2000	Kurimoto, Takashi	430/329
	C	US-6,231,775	05-2001	Levenson et al.	216/67
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	E	US-6,599,438	07-2003	Levenson et al.	216/67
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	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
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NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Sang – Hun et al., "Application of Atmospheric Torch Plasma to Resist and Polymer Removals", Proceedings of the Symposium on Dry process, p. 103 – 108, Nov (2000), Tokyo.
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.